Modification of the Electrical Properties of Porous Silicon by Adsorption of Ammonia Molecules

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Abstract It was studied electrophysical characteristics of porous silicon (PS) layers formed on single-crystalline silicon substrates with both $n$- and $p$-types of conductivity under conditions of adsorption of ammonia molecules. An increase in the conductivity of PS–$n$-Si structures was observed with increasing ammonia concentration. The adsorption of ammonia was shown to give rise to ‘diode-like’ current-voltage characteristics of PS–$p$-Si structures. Spectral characteristics of photovoltage and absorption bands in the infrared spectrum for our structures subjected to ammonia adsorption were studied. We suggested a possible mechanism for the influence of ammonia adsorption on the properties of the PS–silicon structures.

Keywords Porous Silicon, Ammonia Adsorption, Conductivity, Photovoltage, Infrared Spectroscopy

1. Introduction

Porous silicon (PS) reveals a number of unique properties caused by its sponge-like geometrical structure. Owing to an increased bandgap, antireflective properties and a large surface area per unit volume, silicon nanostructures are promising for photoelectronics and sensor electronics [1,2]. A common feature of most gas adsorption sensors based on the PS is usage of adsorption-induced electrical effects that cause substantial changes in the free charge carrier concentrations of the PS and its electrophysical parameters such as electrical conductivity or capacitance [3,4].

On the other side, controlled adsorptions of chemically active or polar molecules purposefully modify the electrical parameters of silicon nanostructures. It was observed transformation of hole-type conductivity of mesoporous silicon into electronic one (see the case of adsorption of NH₃ molecules that exhibit donor properties [5]), or electronic-to-hole conductivity inversion (the case of adsorption of I₂ or Br₂ molecules revealing acceptor properties [6-8]). As a result, it was observed the appearance of photosensitive electrical barriers at the border PS - silicon substrate [7,8]. Nonetheless, applications of adsorption-based techniques for controlling the conductivity type have still not received sufficient attention from researchers.

It should be noted that by now there remains open the problem of doping of nanocrystals. Semiconductor nanocrystals exert resistance to introducing of doping impurities in them: on the one hand there takes place process of self-cleaning of nanocrystals from impurities, on the other hand, these impurities strongly distort the crystal lattice what gives rise to degradation of electrophysical parameters of nanostructures [9,10]. The problems with nanodoping are caused by the fundamental differences in mechanisms which control introduction of impurities in bulk materials and nanoparticles. If in macroscopic solids the main role belongs to thermodynamic issues which impose restrictions on the limiting concentration, then in nanocrystals always is determined by kinetics, and first of all by surface kinetics.

The detailed investigation of the features of doping of semiconductors nanocrystals is of interest since it opens a way to producing new types of semiconductor nanostructures for various applications. The purpose of the work was to investigate the possibility of control the type conductivity nanocrystals PS by adsorption of ammonia molecules. Proof of modification of electronic structure of silicon nanocrystals can be both the changing nature of electrical structures PS – Si under the influence of adsorption of molecules NH₃, and the emergence of photosensitive electric barriers.

2. Experiment

PS nanostructures were prepared by means of photoelectrochemical etching [11] on single-crystal substrates electronic and hole type conductivity with resistivity of 4.5 and 10 Ohm·cm respectively. We used the ethanol solution of hydrofluoric acid (the volume ratio of the components HF:C₂H₅OH = 1:1) as an electrolyte. In order to obtain homogeneous layers, aluminium or silver films were preliminarily deposited on a back surface of the substrates with the aid of a thermo-vacuum technique. These films
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served also as contacts for further measurements. The anodic current density was equal to 30 mA/cm² and the etching time was 5 min. Under the technological conditions mentioned above, mesoporous silicon layers were formed, with the thicknesses of about 10 μm. The structures were divided into samples with areas of about 1 cm². Thus, it has been prepared two series of experimental samples of PS- n-Si and PS – p-Si. The contact with the diameter of ~ 2 mm was deposited on the surface of porous layer, using colloidal carbon.

Modification of the electrical parameters of silicon nanocrystals was carried by adsorption of the molecules NH₃. Control of process adsorption doping was carried out in an atmosphere of ammonia measuring electrophysical parameters of structures PS–Si in the modes of direct and alternating currents during the passage of current through the structure in the direction perpendicular to the surface. The measurements showed that electrical parameters of some samples of the series although being different in the range of 10 % however the character of influence on them the ammonia molecules adsorption was the same.

Photoelectrical phenomena were studied after irradiating the structures from the direction of porous layer perpendicular to its surface. The light of a He-Ne laser was used for that purpose, with the wavelength λ = 0.63 μm and the radiation power 2 mW. The spectral dependences of the photoresponse were measured with a standard optical equipment based upon a diffraction monochromator and a filament lamp (2800 K). The photovoltage spectra were normalized to the curve of black-body radiation with the temperature of 2800 K and then corrected for spectral sensitivity of our setup. The spectral dependence of photoresponse of an industrial silicon photodiode was also measured for a comparison.

Changing the coverage of molecular nanostructures PS due to adsorption of ammonia molecules was investigated by infrared (IR) spectroscopy. Measurement of IR spectra was carried out on a spectrometer AVATAR in the 400–4000 cm⁻¹ range. Identification of absorption bands was carried out based on comparison with the literature data [12-15].

3. Result and Discussion

The reference samples of PS–n-Si and PS–p-Si had symmetrical and nonlinear current-voltage characteristics, indicating the existence in this structure of several potential barriers (Figure 1 and Figure 2).

Our studies reveal that the adsorption of ammonia molecules significantly affects the electrical conductivity of the ‘PS-silicon substrate’. The natures of conductivity changes occurring in the PS–n-Si and PS–p-Si structures turn out to be different. An increase in the conductivity of PS–n-Si nanostructures is observed with increasing ammonia concentration (see Figure 1).

The CVC changes in the PS–p-Si structures occurring under the influence of ammonia adsorption are found to have a more complex character (see Figure 2). Apart from a decrease in the conductivity PS–p-Si observed with an increasing NH₃ concentration, one can see a ‘rectification effect’ inherent to p-n-junctions. Notice that the direct branch of the CVC corresponds in this case to the negative potential at the porous layer. This indicates predominance of one of the potential barriers.

In addition, the adsorption of ammonia molecules gives rise to nonzero value of the current at zero bias. The appearance of a dark potential difference under the influence of adsorption of ammonia was observed in [16] in studies of planar CVC. In our case, the dark potential differences between the contacts (positive sign in PS layer with respect to the silicon substrate) in open-circuit regime increase with increasing the concentration of ammonia, but relax with time (Figure 3). This is indicating electrets properties of experimental structures. Relaxation rate for PS–p-Si structure was higher compared with the structure of PS–n-Si (see inset in Figure 2).
Figure 3. Dependence of the potential difference on the concentration of NH$_3$ in the dark (curves 1 and 2) and under irradiation by the light of He-Ne laser with the intensity of 60 mW/cm$^2$ (curves 1’ and 2’). Curves 1, 1’ refer to the PS–$n$-Si structures and curves 2, 2’ to the PS–$p$-Si ones.

Under illumination the PS surface by He-Ne laser with an intensity of 60 mW/cm$^2$ it was observed a decrease in dark potential differences in the structure of PS–$n$-Si due to adsorption of molecules NH$_3$ and recharge surface PS in structure PS–$p$-Si. Increase in the quantity of adsorbed ammonia molecules drove the value of photovoltage negative polarity at porous layer.

We have investigated the dependences of differential conductivity at the zero bias (measured at a signal testing frequency of 1 MHz and amplitude 25 mV) on the ammonia concentration in the testing cell. As a matter of fact, increasing NH$_3$ concentration leads to increase in the differential conductivity in the case of PS–$n$-Si structure and decreases the same parameter for the PS–$p$-Si structure (Figure 4). A slight increase in the differential conductivity due to photo-generated charge carriers is observed under illumination of the PS surface with the laser light.

The obtained results can be explained in the frame of the following qualitative model. The adsorption of molecular ammonia on the silicon surface induces formation of surface donor levels and the corresponding bending of energy bands. In its turn, the near-surface regions of $p$-Si and $n$-Si get respectively exhausted and enriched with the free charge carriers. Substantial changes in the carrier concentration can be expected under influence of ammonia molecular adsorption in the whole volume of PS nanocrystals, which are characterized by a large specific surface. Therefore the conductivities of the PS–$n$-Si and PS–$p$-Si structures should increase and decrease, respectively.

In the case of PS formed at $p$-Si, the adsorption of NH$_3$ by the silicon nanocrystals reverses hole-type conductivity of the nanocrystals to the electronic type [5]. As a result, formation of electrical barriers (being analogous to the $p$–$n$-junctions in the silicon diodes) is observed at the PS–$p$-Si boundary. So, the structure of ammonia modified PS–$p$-Si can be considered as parallelly arranged $p$–$n$-junctions (see inset in Figure 1). However, we can’t exclude the existence of electrical barriers of other nature (for example, non-linearity of contact) photoconduction of porous layer and, consequently, more complex mechanisms of current passage in these structures.

For obtaining additional information about the nature of influence of the NH$_3$ adsorption on photoelectrical properties of the PS–$p$-Si we have investigated spectral dependences of the photoresponse in that structure. The photovoltage spectra of modified samples at open circuit regime were similar to the photoresponse spectrum of industrial silicon photodiode and were characterized by the wide maximum in the 750–950 nm range (Figure 5).

Figure 4. Dependences of differential conductivity at the zero bias obtained in the dark (curves 1 and 2) and under irradiation by the light of He-Ne laser with the intensity of 60 mW/cm$^2$ (curves 1’ and 2’) on the concentration of NH$_3$. Curves 1, 1’ refer to the PS–$n$-Si structures and curves 2, 2’ to the PS–$p$-Si ones.

Figure 5. Photovoltage spectra for the industrial silicon photodiode (1) and PS–$p$-Si (2) measured at the NH$_3$ concentration 25,2 %

A similarity of the spectral dependence of photoresponse of ammonia modified PS–$p$-Si structure with that of silicon photodiode allows us to suggest that the photovoltage is associated with light absorption in the silicon substrate and separation of photocarriers at the boundary of silicon–PS.
Under illumination in the open-circuit regime, the photo-generated electron–hole pairs are separated by a potential barrier. During this process the electrons are accumulated in the PS nanocrystals, thus creating a potential at the porous layer, which is negative with respect to that of the silicon substrate.

Change of component on the PS surface due to adsorption of ammonia molecules was studied by analyzing the IR transmission spectra of experimental structures ‘PS-silicon substrate’. The most of absorption bands are related to the molecular complexes containing hydrogen and oxygen (Figure 6). The most marked absorption bands were those at frequencies of 620 and 860 cm⁻¹ corresponding to the Si–H₂ and Si–OH deformation modes respectively, and at a frequency of 1100 cm⁻¹ corresponding to valence oscillations of Si–O–Si. In addition, the IR spectra of PS possessed the absorption bands that are related to the hydroxyl groups of Si–OH and the molecular complexes of Si–H₂, Si–H₃.

Adsorption of ammonia molecules by porous silicon leads to a decrease in transmission of infrared radiation over the entire range of measurements. In addition it was observed the bands in the 2350–2400 cm⁻¹ range, which are related to the appearance of new absorption bands in the spectral regions 1100 cm⁻¹ range and shift of the peaks, which proves the change of component on the PS surface due to adsorption of molecules NH₃.

In the same spectral range there were observed the absorption bands that are related to the hydroxyl groups of Si–OH and the molecular complexes of Si–H₂, Si–H₃.

4. Conclusion

Thus it has been shown that adsorption of ammonia molecules modifies the electrical properties of ‘PS-silicon substrate’ structures. Increasing NH₃ concentration leads to increase in the conductivity in the case of PS–n-Si structure and decreases the same parameter for the PS–p-Si structure. The appearance of photosensitive electric barriers in structures PS–p-Si on adsorption of molecules NH₃ can be due to inversion of the hole-type conductivity of the nanocrystals PS to the electronic type. The obtained data suggest the possibility of controlling the conductivity type of PS nanocrystals by adsorption of chemically active or polar molecules.

It has been found that adsorption of ammonia molecules leads to the electret properties of the PS. Probable cause of the observed effect is to change the molecular composition of surface nanocrystals of PS on adsorption of ammonia molecules.

The structures based on ammonia modified PS demonstrated the photovoltaic effect in the visible spectral range what extends the prospects of their use as photodetectors. The obtained experimental results can be also used for the development of electronic devices not only based on porous silicon, but also on systems of semiconductor nanocrystals.

REFERENCES


